

10/510385

Docket No.: 62790 (4590-340)

DT04 Rec'd PCT/PTO 06 OCT 2004
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Pierre-Olivier LEFORT et al.

: Confirmation No.

U.S. Patent Application No.: *pending*

: Group Art Unit:

Filed: *Herewith*

:

For: METHOD FOR THE PRODUCTION OF A MICROSTRUCTURE COMPRISING A VACUUM CAVITY AND A MICROSTRUCTURE

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

This application is related to Application Nos. 09/839,134 and 10/874,753.

Respectfully submitted,

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Date: October 6, 2004
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**INFORMATION DISCLOSURE
CITATION IN AN
APPLICATION**

(PTO-1449)

**ATTY. DOCKET NO.
62790 (4590-340)**

U.S. APPLICATION NO.
Not yet assigned

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not yet assigned

APPLICANT
Pierre-Olivier LEFORT et al.

FILING DATE Herewith	GROUP
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U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

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EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.